

PATENT NUMBER

09/854975

05/14/01

Class	Subclass
<b>ISSUE CLASSIFICATION</b>	

O.I.P.E.	PATENT DATE
SCANNED <i>LM2</i> O.A. <i>AG</i>	

APPLICATION NO. 09/854975	CONT/PRIOR	CLASS <del>216</del>	SUBCLASS <del>02</del>	ART UNIT <del>1746</del>	EXAMINER Umez-Eronini
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William Polinsky  
Thomas Kari  
Mark Bossler

Modified facet etch to prevent blown gate oxide and increase etch chamber life

PTO-2040  
12/88[illegible]

<input type="checkbox"/> <b>TERMINAL DISCLAIMER</b>	<b>DRAWINGS</b>		<b>CLAIMS ALLOWED</b>	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	_____ (Assistant Examiner) (Date)		<b>NOTICE OF ALLOWANCE MAILED</b>  _____	
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____  _____  _____	_____   _____ (Primary Examiner) (Date)		<b>ISSUE FEE</b>  Amount Due Date Paid	
<input type="checkbox"/> The terminal _____ months of this patent have been disclaimed.	_____ (Legal Instruments Examiner) (Date)		<b>ISSUE BATCH NUMBER</b>	
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